

PATENT NUMBER

U.S. UTILITY Patent Application

SCANNED	O.P.E.	PATENT DATE
M.H.	7/5	
	Q.A.	A.G.

APPLICATION NO. 09/731264	CONT/PRIOR	CLASS 438 26	SUBCLASS 05	ART UNIT 2812 -1765	EXAMINER DPO-WLL
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APPLICANTS

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TITLE

Multi-step polish process to control uniformity when using a selective slurry on patterned wafers

PTO-2040
12/89[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed. <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____	_____ (Assistant Examiner) (Date)		NOTICE OF ALLOWANCE MAILED	
	_____ (Primary Examiner) (Date)		ISSUE FEE Amount Due Date Paid	
<input type="checkbox"/> The terminal ____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)		ISSUE BATCH NUMBER	

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